

Report on the Meeting of Joint Working Group CEN/TC 170/WG2 and
ISO/TC 172/SC8/WG3

List of Participants:

Obrecht (Convener)	ESSILOR	FRANCE
M. Tadai	NIKON Corp.	JAPAN
Y. Emori	Tokyo Univ.	JAPAN
Y. Yanagisawa	HOYA Corp.	JAPAN
R. Soliva	INDO	SPAIN
Mr. Fraselle	ESSILOR	FRANCE
F. Checchin	ANFAO	ITALY
G. Padula	Galileo SPA	ITALY
M.A. Jilin	China Opt.	CHINA
Ami Livnat	Rotlex	ISRAEL
John Bradshaw	Pilkington	UK
Rebecca Foster	BSI	UK
Peter Wilkinson		UK
John Redwood	Dept. of Health	UK
Alick Taylor	SOLA Opt.	UK
George Chase	Optical Lab. Assn.	USA
Jeffrey Kosh	Kosh Oph.	USA
Richard Whitney	Amer. Opt. Corp.	USA
Bernie Kratzer	Carl Zeiss	GERMANY
Gunther Guilino	Opt. Werke G.	GERMANY
	Rodenstock	
Wolfgang Grimm	Carl Zeiss	GERMANY
C. Richard Sanders	Oldham's Opt.	USA
David Sklar	SOLA Optical	USA
Kevin O'Connor	SOLA Optical	USA
Seamus Whitney	SOLA AOC	AUSTRALIA
Robert Rosenberg	State Univ. of NY	IRELAND
James Sheedy	Humphrey Inst.	USA
Thomas Loomis	Corning, Inc.	USA
K. Hiraishi	HOYA Optik	USA
Robert Sandor	S.I.S. Std. Div.	SWEDEN
Coulon	ESSILOR	SWEDEN
Galceran	BBGR	FRANCE
Lafont (Secretary)	AFNOR	FRANCE
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